

Refine Search

Search Results -

Terms	Documents
L1 and second anti reflective	44

Database:

US Pre-Grant Publication Full-Text Database
 US Patents Full-Text Database
 US OCR Full-Text Database
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 Derwent World Patents Index
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Search:

L2

Search History

DATE: Monday, July 19, 2004 [Printable Copy](#) [Create Case](#)

<u>Set</u> <u>Name</u> side by side	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
<u>L2</u>	L1 and second anti reflective	44	<u>L2</u>
<u>L1</u>	(ARC or BARC or anti reflective) same (silicon nitride or silicon oxynitride)	1908	<u>L1</u>

END OF SEARCH HISTORY